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Intercalation studies on electron beam evaporated MoO₃ films for electrochemical devices

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Abstract

Now-a-days a large number of extensive research has been focused on electrochromic oxide thin films, owing to their potential applications in smart windows, low cost materials in filters, low cost electrochemical devices and also in solar cell windows. Among the varieties of electrochromic transition metal oxides, the molybdenum oxide (MoO_3) and tungsten oxide (WO_3), form a group of predominant ionic solids that exhibit electrochromic effect. The electrochromic response of these materials are aesthetically superior to many other electrochromic materials, because WO₃ and MoO₃ absorb light more intensely and uniformly. In the present case, we have discussed about the electrochromic behaviour of electron beam evaporated MoO₃ films. Moreover, the MoO₃ film can also be used as a potential electro-active material for high energy density secondary lithium ion batteries; because it exhibits two-dimensional van der Waals bonded layered structure in orthorhombic phase. The films were prepared by evaporating the palletized MoO₃ powder under the vacuum of the order of 1×10^{-5} mbar. The electrochemical behaviour of the films was studied by intercalating/deintercalating the K⁺ ions from KCl electrolyte solutions using three electrode electrochemical cell by the cyclic-voltammetry technique. The studies were carried out for different scanning rates. The films have changed their colour as dark blue in the colouration process and returns to the original colour while the bleaching process. The diffusion coefficient values (D) of the intercalated/deintercalated films were calculated by Randle's Servcik equation. The optical transparency of the coloured and bleached films was studied by the UV-Vis-NIR spectrophotometer. The change in bonding assignment of the intercalated MoO₃ films was studied by FTIR spectroscopic analysis. A feasible study on the effect of substrate temperatures and annealing

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temperatures on optical density (OD) and colouration efficiency of the films were discussed and explored their performance for the low cost electrochemical devices. © 2006 Elsevier B.V. All rights reserved.

Keywords: MoO3 films; Electrochemical devices; K⁺ ion intercalation; Electrochemical analysis; Smart windows

1. Introduction

The transition-metal oxides constitute a very interesting group of semiconducting material because of their technological advantages for application in the field of micro electronics [1] and display systems [2]. Among these materials, molybdenum oxide (MoO_3)derived materials have received increasing attention in recent years due to their potential use in charge-density wave conductors [3], optical materials [4] and electrochemical devices [5]. Concerning the MoO_3 used in these applications, there is a fundamental interest to fabricate layered structure of orthorhombic symmetry MoO_3 (α -phase) with desired chemical stoichiometry and crystallinity. In response to this wide range of application, various preparation techniques have been developed and investigated for the host material MoO_3 [6–8]. In particular, physical properties of MoO_3 such as high volatility have been utilized in thin film growth by vacuum evaporation [9,10]. Furthermore, electron beam evaporation technique [11] has also been investigated in MoO_3 thin film fabrication. Very recently, authors have reported the growth of layered orthorhombic phase electrochromic MoO_3 films by electron beam evaporation technique [12]. The sequential characterization studies like structural, surface morphological, optical, compositional, electrochemical and electrochromic device characterization on electron beam evaporated MoO₃ films have been studied and reported [12–15].

In this work, the effects of substrate temperature (T_{sub}) and annealing temperature (T_{anne}) on electrochromic properties of electron beam-evaporated molybdenum oxide have been reported.

2. Experimental

Thin films were deposited by electron beam evaporation technique on fluorine-doped tin oxide-coated glass substrates (FTO or SnO_2 :F) at different substrate temperatures like 30 (room temperature), 100 and 200 °C. The ablated material of MoO₃ pellets were evaporated by means of resultant electron beam produced from tungsten filament of the electron gun. The films were prepared under the vacuum of the order of about 1×10^{-5} mbar. The films deposited at 30 °C were further annealed at 200 and 300 °C.

The electrochromic properties of the films were investigated on a three-electrode electrochemical cell with a platinum wire as the counter electrode and saturated calomel electrode (SCE) as the reference electrode using an EG & G Model 273A scanning potentiostat. The molybdenum oxide film, as the working electrode, was electrochemically cycled in 0.05 and 0.1 M KCl electrolyte solution. Optical measurements were made with a Hitachi-3400 UV–Vis–NIR spectrophotometer. All spectra were taken over the wavelength range 300-2500 nm. In order to identify the bonding assignment of intercalated/deintercalated MoO₃ films cycled in 0.1 M KCl electrolyte solutions, the IR

absorption spectroscopic analysis has been carried out using the Perkin Elmer-make Paragon 500 FTIR spectrometer.

3. Results and discussion

3.1. Electrochromic properties and electrochemical device results

In our previous work [12–15], we showed by XRD measurements, the MoO_3 films have orthorhombic phase. Also the layered nature of films was identified from the SEM and AFM analysis. The film purity and stoichiometric nature of the films were confirmed from the XPS study. The electrochromic performance of MoO_3 films and their chemical stability



Fig. 1. Cyclic voltammograms of MoO₃ films prepared at different conditions, cycled in 0.05 M KCl electrolyte solutions: (a) $T_{sub} = RT$, (b) $T_{sub} = 100$ °C, (c) $T_{sub} = 200$ °C, (d) $T_{anne} = 200$ °C and (e) $T_{anne} = 300$ °C.

in electrochemical cell was evaluated by the cyclic-voltammetry technique and electrochromic device cell characterization, cycled in H_2SO_4 electrolyte solutions. In the present work, we focused on how the electrochromic performance of MoO₃-based cell towards KCl electrolyte solution is modified by the substrate and annealing temperatures. Moreover, compared with WO₃ films there are some limited reports available for the electrochemical analysis of MoO₃ films. Some of them are related to electrochromic behaviour of MoO₃ films by the insertion/extraction of Li⁺ and H⁺ ions [5,16]. At the same time, to the best of our knowledge no reports are available for the intercalation of K⁺ ions from KCl electrolyte solution for electron beam-evaporated MoO₃ films.

The electrochromic properties of MoO_3 thin film electrode was evaluated by inserting K^+ ions in an electrochemical cell containing 0.05 and 0.1 M KCl electrolyte solutions. The process of ion intercalation and deintercalation was noted during cycling of different sweep rates such as 100, 200 and 300 mV/s. In these processes the applied potential lies in the range between -1.2 to $+1.2 V_{SCE}$. During negative potential of the scan (i.e., cathodic scan), we observed a dark blue colouration of the films whereas the films became colourless in the positive potential (i.e., anodic scan). This is attributed mainly to the electrochemical process involved with the reaction represented by the formation of 'molybdenum bronze'. All the samples were stable throughout the scan rates and also up to 1×10^3 cycles of colouration/bleaching. Hence, the observation of film colouration \leftrightarrow bleaching behaviour further confirmed their perfect electrochemical performance. The diffusion coefficient (*D*) of ions during intercalation and deintercalation can be evaluated by employing the Randles–Servcik equation [15].

Figs. 1(a)–(e) show the cyclic voltammograms (CV) recorded in 0.05 M KCl solution for MoO₃ films prepared at $T_{sub} = 30 \text{ °C}$, $T_{sub} = 100 \text{ °C}$, $T_{sub} = 200 \text{ °C}$, $T_{anne} = 200 \text{ °C}$ and $T_{anne} = 300 \text{ °C}$, respectively. The extracted electrochemical parameters (anodic peak

Sample	Scan rate, υ (mV/s)	Cathodic spike current, <i>i</i> _{pc} (mA)	Anodic peak current, i _{pa} (mA)	Diffusion coefficient, $D (\text{cm}^2/\text{s})$	
				For <i>i</i> _{pc}	For <i>i</i> _{pa}
MoO ₃ /RT	100	5.00	6.20	1.35×10^{-8}	2.07×10^{-8}
-,	200	10.60	6.80	3.03×10^{-8}	1.25×10^{-8}
	300	17.50	7.90	$5.51 imes 10^{-8}$	1.12×10^{-8}
MoO ₃ /100 °C	100	5.70	4.00	1.75×10^{-8}	8.65×10^{-9}
21	200	6.40	4.40	1.10×10^{-8}	5.23×10^{-9}
	300	7.10	5.40	9.08×10^{-9}	5.25×10^{-9}
MoO ₃ /200 °C	100	5.00	3.10	1.35×10^{-8}	5.19×10^{-9}
2,	200	5.30	3.70	7.59×10^{-9}	3.70×10^{-9}
	300	5.70	4.30	$5.85 imes 10^{-9}$	3.33×10^{-9}
MoO ₃ /RT/	100	2.50	0.40	3.37×10^{-9}	8.65×10^{-11}
$T_{\rm anne}$: 200 °C	200	2.80	0.47	2.11×10^{-9}	5.97×10^{-11}
unite	300	3.30	0.56	1.96×10^{-9}	5.65×10^{-11}
MoO ₃ /RT/	100	0.9	0.20	4.37×10^{-10}	2.16×10^{-11}
T _{anne} : 300 °C	200	1.1	0.25	3.27×10^{-10}	1.68×10^{-11}
	300	1.3	0.32	3.04×10^{-10}	1.84×10^{-11}

Table 1 Extracted electrochemical parameters of MoO₃ films in 0.05 M KCl electrolyte solution

current (i_{pa}) , cathodic spike current (i_{pc}) and diffusion coefficient (D)) from these CV diagrams are given in Table 1. The electrochemical curves and their evaluated parameters for MoO₃ films cycled in 0.1 M KCl solution are shown in Figs. 2(a)–(e) and Table 2, respectively. In this case, the evaluated *D* values of MoO₃ films vary between 8.65 × 10⁻¹¹ and 5.51 × 10⁻⁸ cm²/s and 6.50 × 10⁻¹² and 1.72 × 10⁻⁸ cm²/s for 0.05 and 0.1 M electrolyte solutions, respectively. Crystalline α -MoO₃ bulk samples have diffusion constants that are strongly orientation dependent, which is expected from the layered crystal structure. Thus, the diffusion coefficient of H⁺ ion lie between 10⁻⁸ and 10⁻⁶ cm²/s along the MoO₆-based chains and was ~10⁻¹⁵ cm²/s perpendicular to them [16–18]. In addition, the magnitude of anodic peak and cathodic spike current decreases with increasing substrate and annealing temperature than the room temperature-prepared films.



Fig. 2. Cyclic voltammograms of MoO₃ films cycled in 0.1 M KCl electrolyte solutions: (a) $T_{sub} = RT$, (b) $T_{sub} = 100$ °C, (c) $T_{sub} = 200$ °C, (d) $T_{anne} = 200$ °C and (e) $T_{anne} = 300$ °C.

Sample	Scan rate, υ (mV/s)	Cathodic spike current, <i>i</i> _{pc} (mA)	Anodic peak current, <i>i</i> _{pa} (mA)	Diffusion coefficient, D (cm ² /s)	
				For <i>i</i> _{pc}	For $i_{\rm pa}$
MoO ₃ /RT	100	11.30	5.30	1.72×10^{-8}	3.79×10^{-8}
	200	14.00	8.10	1.32×10^{-8}	4.43×10^{-8}
	300	18.00	8.60	1.45×10^{-8}	3.33×10^{-8}
MoO ₃ /100 °C	100	11.00	4.80	1.63×10^{-8}	3.11×10^{-9}
	200	13.30	7.10	1.19×10^{-8}	3.40×10^{-9}
	300	14.50	8.50	9.47×10^{-9}	3.25×10^{-9}
MoO ₃ /200 °C	100	5.20	3.90	3.65×10^{-8}	2.05×10^{-9}
	200	7.30	4.30	3.60×10^{-9}	1.24×10^{-9}
	300	9.00	4.70	3.64×10^{-9}	9.95×10^{-10}
MoO ₃ /RT/	100	2.50	0.35	8.44×10^{-10}	1.65×10^{-11}
$T_{\rm anne}$: 200 °C	200	3.60	1.00	8.75×10^{-10}	6.75×10^{-11}
	300	4.50	1.50	9.12×10^{-10}	1.01×10^{-10}
MoO ₃ /RT/	100	0.93	0.13	1.16×10^{-10}	2.28×10^{-12}
$T_{\rm anne}$: 300 °C	200	1.06	0.25	7.59×10^{-11}	4.22×10^{-11}
	300	1.25	0.38	7.03×10^{-10}	6.50×10^{-12}

Table 2 Extracted electrochemical parameters of MoO₃ films in 0.1 M KCl electrolyte solution

This shows that the films produced at lower substrate and annealing temperatures could be intercalated to a greater extent than higher temperature-produced films. As observed in our earlier work [12,13], the lower temperature-produced films is amorphous and highly disordered. Reichman and Bard [19] said that the disorder enhances the electrochromic effect. The MoO₃ films deposited at $T_{sub} = 200 \text{ °C}$ and $T_{anne} = 300 \text{ °C}$ are highly crystalline and preferably oriented along (0 2 1) planes, and therefore leads to the minimum values of anodic peak current and cathodic spike current as indicated in Tables 1 and 2.

The detailed description of electrochemical cell characterization for MoO₃ films was reported earlier [15]. The change in optical transmittance of the coloured and bleached films was studied by using Hitachi-3400 UV-Vis-NIR spectrophotometer. Samples were removed from the electrolyte for spectral transmittance measurements, but the spectra were complete within minutes of the colouration being completed, so self-bleaching [20] of the films was not expected to be a problem in this work. The optical transmittance spectra of MoO₃ films prepared at $T_{sub} = 30, 200 \,^{\circ}\text{C}$ and $T_{anne} = 300 \,^{\circ}\text{C}$, cycled in 0.1 M KCl electrolyte solution are shown in Figs. 3(a)-(c), respectively. The observed optical transmittance of coloured and bleached states enumerated the films are having good electrochromic colouration. From these optical transmittance spectra of coloured and bleached states, the optical density (OD) and colouration efficiency (CE) of the films were calculated at two different wavelengths like 633 and 1033 nm and they are summarized in Table 3. Molybdenum oxide is known to have optical absorption maximum closer to the human eye sensitivity maximum. Hence, we would like to study spectral transmittance of MoO₃ films in the visible region ($\lambda \sim 633$ nm). The transmittance in the visible range has been found to be significantly different for the films in bleached and coloured states though



Fig. 3. Optical transmittance spectra of MoO₃ films in ECD cells, cycled in 0.1 M KCl electrolyte solutions: (a) $T_{sub} = RT$, (b) $T_{sub} = 200$ °C and (c) $T_{anne} = 300$ °C.

the shape has no apparent change. This effect could make them useful in electrochromic display devices and smart windows applications. Also in order to identify the performance of the films in the infrared range, we have measured the transmittance at a wavelength of

0.40

0.32

Evaluated ECD cell parameters of MOO_3 nims in 0.1 M KCl electrolyte solution							
Sample	Optical densit	y (OD) at	Colouration efficiency (CE) (cm ² /C) at				
	$\lambda \sim 633 \text{ nm}$	$\lambda \sim 1033 nm$	$\lambda \sim 633 \mathrm{nm}$	$\lambda \sim 1033 \text{ nm}$			
MoO ₃ /RT	0.32	0.37	30	35			

14

16

Table 3 Evaluat

0.31

0.26

1033 nm. The higher optical modulation was observed in the visible range of the spectra; whereas the lower optical modulation was observed in the infrared range, which enumerated the suitability of these films in electrochromic device and smart window applications. Fig. 4 shows the graphical representation of evaluated optical density and colouration efficiency of MoO₃ films cycled in 0.1 M KCl electrolyte solution. The maximum colouration efficiency of 35 cm²/C was obtained for films prepared at room temperature. The colouration efficiency reported for molybdenum oxide obtained from oxalatomolybdate complexes is 45 and $30 \text{ cm}^2/\text{C}$, reported by Belanger and Laperriere [21]. Laperriere et al. [22] observed that the coloration efficiency of MoO₃ films decreases with increasing annealing temperature. Thus, it reveals that the observations of present work on electrochemical analysis of MoO₃ films are supported with the reported literature. It enumerated the MoO₃ films prepared in the present work, could be an aesthetic material in electrochemical device applications.

3.2. FTIR analysis

MoO₃/200 °C

 $MoO_3/RT/T_{anne}$: 300 °C

The intercalated/deintercalated MoO₃ films in 0.1 M KCl electrolyte solutions have been subjected to IR spectroscopic investigation to identify their bonding assignments. The FTIR spectra of intercalated/deintercalated MoO_3 films prepared at conditioned $T_{sub} = 30 \degree C$, $T_{sub} = 200 \degree C$ and $T_{anne} = 300 \degree C$, cycled in 0.1 M KCl electrolyte solution are shown in Figs. 5(a)-(c). A group peaks between $650-550 \text{ cm}^{-1}$ could be observed as same for the MoO₃ powder [23]. However, the peaks around $551-447 \text{ cm}^{-1}$ are typical stretching modes of Mo–O of α -MoO₃ structure [7,24]. The absorption peak at around $833 \,\mathrm{cm}^{-1}$ is related to Mo–O bond vibrations in the orthorhombic modification of MoO₃ [25]. The observation of peak at about $942-964 \text{ cm}^{-1}$, is shifted to 995 cm^{-1} with increasing substrate and annealing temperatures is assigned to the Mo and single-Mo-coordinated oxygen (i.e., terminal oxygen) stretching [24]. This peak shift suggests stronger types of Mo-O (terminal oxygen) and Mo-O-Mo (common oxygens and bridge oxygens) bonding being developed, which in turn confirms the XRD result that high-temperature condition favours the layered α -MoO₃ phase [23]. A pronounced H–O–H deformation band was observed at 1631 cm⁻¹. This is due to the structural water coordinated as H₂O molecules from the aqueous KCl electrolyte solutions [26]. A broad band around $3500 \,\mathrm{cm}^{-1}$ corresponds to the O-H stretching vibration. The coloration peak was observed at about 3700 cm⁻¹. The observed Mo-O-Mo peak attributes the stability of the films after the intercalation-deintercalation in the electrolytes, which proposes the suitability of MoO_3 films in electrochromic device applications.

18

20



Fig. 4. Variation of the electrochromic device parameters of MoO_3 films with respect to substrate and annealing temperatures in 0.1 M KCl electrolyte solutions: (a) optical density (OD), (b) colouration efficiency (CE).

4. Conclusions

This paper has described the intercalation studies on MoO_3 thin films prepared by electron beam evaporation technique. The effect of substrate temperature and annealing temperature on the electrochromic properties was studied by electrochemical and optical techniques. As observed from the results, the as-deposited films at room temperature



Fig. 5. FTIR spectra of intercalated MoO₃ films in 0.1 M KCl electrolyte solutions: (a) $T_{sub} = RT$, (b) $T_{sub} = 200 \,^{\circ}C$ and (c) $T_{anne} = 300 \,^{\circ}C$.

exhibit the good electrochemical performance and colouration efficiency than the higher temperature deposited and annealed films. The cyclic-voltammetry analysis and electrochromic device cell characterization resulted the electron beam evaporated MoO₃ films are highly stable in the liquid electrolyte solutions. This was also confirmed from the observation of Mo–O–Mo peak in FTIR analysis.

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